

# I K M REAZ RAHMAN

Ph.D. Candidate at University of California, Berkeley

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## EDUCATION

### Doctor of Philosophy in Electrical and Electronics Engineering

📅 2021 – 2026 (Expected)

📍 UC Berkeley

### Master of Science in Electrical and Electronic Engineering

📅 2018 – 2020

📍 BUET

CGPA: 3.92/4.00

### Bachelor of Science in Electrical and Electronic Engineering

📅 2013 – 2017

📍 BUET

CGPA: 3.96/4.00, Position: 5th out of 214 students

### Advanced Level, Edexcel

📅 2011 – 2012

📍 Maple Leaf International School

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## PUBLICATIONS

### Journal Articles

Rahman, IKM Reaz, et al. "Deterministic Patterning and Alignment of Tellurium Quantum Wires using Nanoscale Templates." submitted in *Nature*.

Rahman, IKM Reaz, et al. "Thermally Stable Ruthenium Contact for Robust *p*-Type Tellurium Transistors." *Nano Letters* 25.10 (2025): 3956-3963.

<https://doi.org/10.1021/acs.nanolett.4c06553>

Geng, Jamie, et al. "Unusually Strong Near-Infrared Photoluminescence of Highly Transparent Bulk InSe Flakes." *Advanced Functional Materials* 35.3 (2025): 2413672.

<https://doi.org/10.1002/adfm.202413672>

Byeon, Kyeong-Jae, et al. "Quantitative Characterization of ZrO<sub>2</sub> Gate Dielectric Interface with Tellurium." *Applied Physics Letters* 126.23 (2025).

<https://doi.org/10.1063/5.0267586>

Kim, Inha, et al. "Low Contact Resistance WSe<sub>2</sub> *p*-Type Transistors with Highly Stable, CMOS-Compatible Dopants." *Nano Letters* 24.43 (2024): 13528-13533.

<https://doi.org/10.1021/acs.nanolett.4c02948>

Rahman, IKM Reaz, et al. "Gate Controlled Excitonic Emission in Quantum Dot Thin Films." *Nano Letters* 23.22 (2023): 10164-10170.

<https://doi.org/10.1021/acs.nanolett.3c02456>

Higashitarumizu, Naoki, et al. "Anomalous thickness dependence of photoluminescence quantum yield in black phosphorus." *Nature Nanotechnology* 18.5 (2023): 507-513.

<https://doi.org/10.1038/s41565-023-01335-0>

Rahman, IKM Reaz, et al. "Low Voltage AC Electroluminescence in Silicon MOS Capacitors." *Applied Physics Letters* 121.19 (2022): 193502.

<https://doi.org/10.1063/5.0120507>

## RESEARCH INTEREST

Electrical and optical characterization of low-dimensional systems and electronic devices with an emphasis on performance enhancement in optoelectronic applications. Simulation and analytical modeling of nanoscale device and state-of-the-art solid state devices. Nanowire fabrication and simulation using novel materials.

## RESEARCH EXPERIENCE

### Aligning crystal orientation of Tellurium using nanoscale templates

Supervisor: Prof. Ali Javey, UC Berkeley

- Exploring control over the intrinsic anisotropy of tellurium to reduce device variability
- Probing quantum transport which can now be accessed from the aligned crystal structure

### Performance limits of tellurium based semiconductors

Supervisor: Prof. Ali Javey, UC Berkeley

- Exploring thermally stable contacts to tellurium for back end of the line integration to CMOS technology
- Probing the performance of tellurium transistors in nanoscale

### Enhancing brightness in van der Waals semiconductors through electrostatic doping and strain.

Supervisor: Prof. Ali Javey, UC Berkeley

- Investigation of the transition from free carriers to an excitonic system in black phosphorus as a function of thickness scaling
- Suppressing non-radiative recombination in layered van der Waals semiconductors by application of strain

### Gated Photoluminescence in Quantum Dot Thin Films

Supervisor: Prof. Ali Javey, UC Berkeley

- Optimizing a device structure for gating thin film quantum dots
- Analyzing the various recombination pathways under charge injection

### Electroluminescence in Silicon MOS Capacitors

Supervisor: Prof. Ali Javey, UC Berkeley

- Fabrication of MOS devices in CMOS framework.
- Optical and electrical characterization of device performance metrics.

### Electrostatic Characterization and Drain Current Modeling of Inversion Type InGaAs Gate-All-Around MOSFET

Supervisor: Dr. Quazi D. M. Khosru, BUET

- Solving quasi 2-D Poisson equation in a continuous manner with inclusion of short channel non-ideal effects.

## PUBLICATIONS

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Uddin, Shiekh Zia, et al. "Efficiency Roll-Off Free Electroluminescence from Monolayer WSe<sub>2</sub>." *Nano Letters* 22.13 (2022): 5316-5321.

<https://doi.org/10.1021/acs.nanolett.2c01311>

Rahman, IKM Reaz, Khan, Md Irfan, and Khosru, Quazi DM. "Analytical drain current and performance evaluation for inversion type InGaAs gate-all-around MOSFET." *AIP Advances* 11.6 (2021): 065108.

<https://doi.org/10.1063/5.0052718>

Rahman, IKM Reaz, Khan, Md Irfan, and Khosru, Quazi DM. "Electrostatic characterization and threshold voltage modeling of inversion type InGaAs gate-all-around MOSFET." *Journal of Computational Electronics* 20.4 (2021): 1504-1512.

<https://doi.org/10.1007/s10825-021-01716-5>

Khan, Md Irfan, Rahman, IKM Reaz, and Khosru, Quazi DM, "Surface potential-based analytical modeling of electrostatic and transport phenomena of GaN nanowire junctionless MOSFET," *IEEE Transactions on Electron Devices* 67.9 (2020): 3568-3576.

<https://doi.org/10.1109/TED.2020.3011645>

Rahman, IKM Reaz, Khan, Md Irfan and Khosru, Quazi DM. "A rigorous investigation of electrostatic and transport phenomena of GaN double-channel HEMT." *IEEE Transactions on Electron Devices* 66.7 (2019): 2923-2931.

<https://doi.org/10.1109/TED.2019.2915837>

### Conference Proceedings

Khan, Md Irfan, IKM Reaz Rahman, and Quazi DM Khosru. "Analytical Modeling of Capacitance-Voltage Characteristics of GaN Nanowire Junctionless MOSFET." 2020 *IEEE 20th International Conference on Nanotechnology (IEEE-NANO)*. IEEE, 2020.

<https://doi.org/10.1109/NANO47656.2020.9183461>

Rahman, IKM Reaz, et al. "Analytical modeling of electrostatic characteristics of enhancement mode GaN double channel HEMT." 2018 *IEEE 13th Nanotechnology Materials and Devices Conference (NMDC)*. IEEE, 2018.

<https://doi.org/10.1109/NMDC.2018.8605851>

## WORK EXPERIENCE

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### Assistant Professor

📅 2021–Present (On Leave) 📍 BUET

Department of Electrical and Electronic Engineering

### Lecturer

📅 2018–2021 📍 BUET

Department of Electrical and Electronic Engineering

### Educational and Outreach Coordinator

📅 2019–2021 📍 IEEE

IEEE ED/SSCS Bangladesh Chapter

## RESEARCH EXPERIENCE

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### Analytical Modeling of GaN Nanowire Junctionless MOSFET using surface potential

Supervisor: Dr. Quazi D. M. Khosru, BUET

- Solution of Poisson equation using regional approach, gate voltage correction for short channel effect, inclusion of non-ideal effects and transport analysis.

### A Rigorous Investigation of GaN Double Channel MOS-HEMT

Supervisor: Dr. Quazi D. M. Khosru, BUET

- Self-consistent solution of Schrodinger-Poisson equation leading to spatial distribution of carrier density, drain current formulation including inter channel coupling.

## TECHNICAL SKILLS

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### Skillset

- Microfabrication, Nanofabrication, Physical vapor deposition, Electrical characterization, SEM, AFM, Raman spectroscopy, Optical spectroscopy

### Programming Languages

- Matlab, Python, Verilog, Latex

### Software

- TCAD:Sentaurus Device, Lumerical, COMSOL Multiphysics

## RELEVANT COURSEWORK

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### Graduate Courses (UC Berkeley)

- Integrated-Circuit Devices (EE230A), Introduction to Optical Engineering (EE218A), Lightwave Devices (EE232), Introduction to Microelectromechanical Systems (EE247A)

### Undergraduate Courses

- Solid State Devices, Compound Semiconductor and Heterojunction Devices, Semiconductor Device Theory, MOS Devices, Optoelectronics, Power Electronics, Control Systems, Electronics (I + II), Energy Conversion, VLSI, Microprocessor and Interfacing, Measurement and Instrumentation, Communication Theory, Digital Signal Processing